IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Patent Application of:

Hideto OHNUMA

Serial No. 10/053,572

Filed: January 24, 2002

For: METHOD OF MANUFACTURING

SEMICONDUCTOR DEVICE

Group Art Unit: 2812

Examiner: J. Kennedy

CERTIFICATE OF MAILING

I hereby certify that this correspondence is being deposited with the United States Postal Service with sufficient postage as First Class Mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on February 16,

2005.

INFORMATION DISCLOSURE STATEMENT

Honorable Commissioner of Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the provisions of 37 C.F.R. 1.56 and 37 C.F.R. 1.97-1.99, Applicant submits herewith a Form PTO-1449 listing information known to Applicant and requests that this information be made of record in the above identified application. Copies are submitted herewith in accordance with 37 C.F.R. 1.98(a).

Although not written in the abstract, JP 04-290467 discloses a method for forming a poly-Si film over a substrate 11 by CVD, forming a gate insulating film 13 over the poly-Si film by CVD, sputtering, or by heating a surface of the poly-Si film, and doping B- into the poly-Si film through the gate insulating film 13 (see Figure 2).

The examiner's attention is particularly directed to the following documents: U.S. Patent Publication No. 2001/0034089, U.S. Patent No. 6,165,876 and U.S. Patent No. 6,353,244, all to Yamazaki et al.

This Information Disclosure Statement is being submitted with an RCE. Therefore, no fee is required.

Respectfully submitted,

Eric J. Robinson

Reg. No. 38,285

Robinson Intellectual Property Law Office, P.C.

PMB 955

21010 Southbank Street

Potomac Falls, Virginia 20165

(571) 434-6789

Approved for use through 10/31/2002. OMB 0651-0031

U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE Under the Paperwork Reduction Act of 1995, no persons are required to respond to a collection of information unless it contains a valid OMB control number. Complete if Known Substitute for form 1449A/PTO 10/053,572 Application Number INFORMATION DISCLOSURE January 24, 2002 Filing Date STATEMENT BY APPLICANT Hideto OHNUMA First Named Inventor (use as many sheets as necessary) 2812 Group Art Unit J. Kennedy Examiner Name of Attorney Docket Number 0756-2422 Sheet

					U.S. PATENT DOCUM	ENTS			
Examiner Initials*	Cite No.	Nun	U.S. Patent Document Number Kind Code ² (If known)		Name of Patentee or Applicant of City Document	Date of Publication of Cit	Pages, Columns, Lines, Wi Passages or Relevant Figu		
	+	20	01/0034089		'amazaki et al.	10/25/2001			
	-		391,468		to et al.	06/24/1975			
			168,990		enie et al.	09/25/1979			
	-		169,740		Calbitzer et al.	10/02/1979			
			199,773		Goodman et al.	04/22/1980			
	+		163,492	_	faeguchi	08/07/1984			
	-		172,871		reen et al.	09/25/1984			
	4,4727,044				amazaki	02/23/1988			
	 	4,775,641			Ouffy et al.	10/04/1988			
	4,773,641 4,959,700 5,064,775 5,104,818			Yamazaki Chang		09/25/1990			
						11/12/1991			
				ilver	04/14/1992				
	+	5,111,266			urumura et al.	05/05/1992		**	
	5,132,754				erikawa et al.	07/21/1992			
	5,132,734			Yamazaki 08/25/1992					
		, ,	1 12,5 1 1		OREIGN PATENT DOCI				
Examiner Initials*	Cite No. ¹	Foreign Patent Documer Kind Office ³ Number ⁴ (if)		Code ³	Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	т•	
	 	JP	03-189626			08/19/1991		Abst.	
	+	JP	04-290467	+-		10/15/1992		Abst.	
.	+	JP	04-302147	_	 	10/26/1992		Abst.	
		JP	05-082552			04/02/1993		Abst.	
-	+	JP	10-302707	_		11/13/1998		Abst.	
	-	JP	64-007559	+-	-	01/11/1989		Abst.	
	1			PRIOR	ART - NON PATENT LITE	· 	! <u></u>		
Examiner Initials	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.)., date, page(s), volume-issue number(s), publisher, city and/or country where published.							
		Y. MISHIMA et al., Implantation Temperature Effect on Polycrystalline Silicon By Ion Shower Doping, Journal of Applied Physics, Vol. 74, No. 12, December 15, 1993, Pages 7114-7117.							
		S. WOLF, et al., Silicon Processing for the VLSI Era, Vol. 1, January 1, 1986, Pages 175-180, 323-325.							
		H. SCHENK, et al., <i>Polymers for Light Emitting Diodes</i> , Proceedings of the 19 th International Display Research Conference, September 6, 1999, Pages 33-37.							

Examiner	Date	
Signature	 Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

PTO/SB/08A (08-00)
Approved for use through 10/31/2002. OMB 0651-0031
U.S. Patent and Trademark Office: U.S. DEPARTMENT OF COMMERCE

Substitute for form 1449A/PTO INFORMATION DISCLOSURE STATEMENT BY APPLICANT				C	omplete if Known	10	78
				Application Number	10/053,572	7	٠, ١
				Filing Date	January 24, 2002	FER : 6	
SIAI			_	First Named Inventor	Hideto OHNUMA	3	2005
(use as many sheets as necessary)			iry)	Group Art Unit	2812	(E)	A.
				Examiner Name	J. Kennedy	E PRADEN	ARKON
Sheet	2	of	2	Attorney Docket Number	0756-2422		

U.S. PATENT DOCUMENTS						
Examiner Initials	Cite No. ¹	U.S. Patent Document Number Kind Code ² (If known)	Name of Patentee or Applicant of Cited Document	Date of Publication of Cited Document MM-DD-YYYY	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	
	1	5,154,946	Zdebel	10/13/1992		
		5,244,820	Kamata et al.	09/14/1993		
	 	5,247,190	Enjoyd at al	09/21/1993		
	<u> </u>	5,270,224	Furumura et al.	12/14/1993	· · · · · · · · · · · · · · · · · · ·	
	<u> </u>	5,313,077	Yamazaki	05/17/1994		
		5,315,132	Yamazaki	05/24/1994		
		5,396,084	Matsumoto	03/07/1995		
		5,399,502	Friend et al.	03/21/1995	·	
	-	5,403,762	Takemura	04/04/1995		
	-		Yamazaki et al.	01/16/1996		
		5,485,019. 5,486,774	Douseki et al.	01/23/1996		
	_		Zhang et al.	01/30/1996		
	<u> </u>	5,488,000	Takayama et al.	03/26/1996		
	 	5,501,989	Yamazaki	05/07/1996		
	 	5,514,879	Furumura et al.	05/21/1996		
		5,518,937	Racanelli et al.	07/02/1996		
	-	5,532,175	Yamazaki	08/06/1996		
	-	5,543,636	Theodore et al.	10/15/1996		
	 	5,565,690	Takemura	12/03/1996		
		5,581,092		01/14/1997		
		5,594,371	Douseki			
	 	5,614,732	Yamazaki	03/25/1997		
	 	5,643,826	Ohtani et al.	07/01/1997		
	 	5,672,541	Booske et al.	09/30/1997		
	ļ	5,859,445	Yamazaki	01/12/1999		
	ļ	5,904,509	Zhang et al.	05/18/1999		
	ļ	5,914,498	Suzawa et al.	06/22/1999		
	<u> </u>	5,923,962	Ohtani et al.	07/13/1999		
	 	5,981,974	Makita	11/09/1999	<u> </u>	
	<u> </u>	6,011,277	Yamazaki	01/04/2000		
	<u> </u>	6,013,930	Yamazaki et al.	01/11/2000		
	<u> </u>	6,165,876	Yamazaki et al.	12/26/2000		
	ļ	6,218,219	Yamazaki et al.	04/17/2001		
	1	6,235,563	Oka et al.	05/22/2001		
	ļ	6,258,638	Tanabe et al.	07/10/2001		
		6,353,244	Yamazaki et al.	03/05/2002		
		6,455,360	Miyasaka	09/24/2002		
		6,633,597	Abe	10/14/2003		
		5,583,369	Yamazaki et al.	12/10/1996		
				<u></u>	<u></u>	

Examiner	Date	
Signature	 Considered	

^{*}EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.